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Zinc Vacancy - Hydrogen Complexes as Major Defects in ZnO Nanowires Grown by Chemical Bath Deposition

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ABSTRACT

Crystal defects in unintentionally doped ZnO nanowires grown by chemical bath deposition (CBD) play a capital role on their optical and electrical properties, governing the performances of many nanoscale engineering devices. However, the nature of these crystal defects is still highly debated. In particular, the hydrogen-related defects have not been explored in detail yet although the growth medium operates in aqueous solution. By using four-point probe resistivity measurements, we show that ZnO nanowires grown by CBD using zinc nitrate and hexamethylenetetramine exhibit a high electrical conductivity with electron densities ranging from 2.7 x 10^{18} to 3.1 x 10^{19} cm⁻³. Most of them have a metallic electrical conduction. By combining density-functional theory calculations with cathodoluminescence and Raman spectroscopy, we reveal that the high electrical conductivity mostly originates from the formation of interstitial hydrogen in bond-centered sites (H_{BC}) and of zinc vacancy – hydrogen $(V_{Zn}-nH)$ complexes. In particular, the H_{BC} and $(V_{Zn}-3H)$ complex are found to act as two shallow donors with a very low formation energy, for which the most stable configurations are reported. Additionally, this combined theoretical and experimental approach allows us to revisit the highly debated origin of the visible and ultra-violet emission bands in the luminescence spectra. They are found to be mostly related to V_{Zn} and $(V_{Zn}-nH)$ complexes located in the bulk and on the surfaces of ZnO nanowires. These findings represent an important step forward in the identification of the predominant native and extrinsic defects driving the electronic structure properties of ZnO nanowires grown by CBD. They further reveal the significance of hydrogen engineering to tune the source of crystal defects for optimizing the physical properties of ZnO nanowires.

I. INTRODUCTION

ZnO nanowires (NWs) are of high interest as building blocks in a vast number of nanoscale devices.¹⁻⁵ As a low-cost, low-temperature and easily implemented process,⁶ chemical bath deposition (CBD) represents the most widely used technique to form ZnO NWs with a broad range of morphology using the spontaneous/selective area growth approaches on unpatterned/patterned ZnO seed layers, respectively.⁷ Until now, most of the efforts have been dedicated to optimizing the structural properties of ZnO NWs grown by CBD, specifically their dimensions *(i.e.* diameter, length), arrangement, and verticality.⁸⁻¹⁰ In contrast, the nature of intrinsic/extrinsic point defects in the center of unintentionally doped ZnO NWs grown by CBD along with their correlated optical/electrical properties are still controversial, to a large extent, despite its primary importance. A couple of investigations of the electrical properties of unintentionally doped ZnO NWs grown by CBD have shown that their electrical conductivity is typically high with an expected electron density lying in the range of $5x10^{17}$ to $1.5x10^{19}$ cm⁻ ^{3.11-15} This high electron density indicates the incorporation and formation of a high density of intrinsic/extrinsic point defects in their center, which should carefully be identified and mastered.

The nature of intrinsic/extrinsic point defects governing the electronic structure properties of ZnO in its form of single crystals and epitaxial films has been highly debated over the last two decades.¹⁶⁻¹⁷ The oxygen vacancy (V_O) with its low formation energy over a broad range of Fermi level has been identified, in the past, as one of the major intrinsic point defects. A consensus has however emerged progressively on the fact that *VO* acts as a deep donor and thus it cannot account for the high electron density in unintentionally doped ZnO .¹⁸⁻²⁶ The zinc vacancy (V_{Zn}) with its low formation energy when the Fermi level is close to the conduction band minimum (CBM) has been shown to be formed as well, but it acts as a deep acceptor and thus it cannot explain the source of n-type conductivity in unintentionally doped ZnO either.²⁰⁻

²¹ Instead, the predominance of hydrogen-related defects has been more and more emphasized by using density-functional theory (DFT) calculations from the pioneered work of Van de Walle, showing that hydrogen exhibits a unique positive charge state over the expected range of Fermi level in ZnO.27 Hydrogen can be incorporated in ZnO in the form of interstitial hydrogen (H_i) ,²⁷ substitutional hydrogen on the oxygen lattice site (H_0) ,²⁸ as well as zinc vacancy – hydrogen (V_{Zn} -*n*H) defect complexes where *n* is the number of involved H_i atoms and typically lies in the range of 1-4.²⁹⁻³⁰ The presence of hydrogen in ZnO has been experimentally proved by electron paramagnetic resonance (EPR) and electron nuclear double resonance (ENDOR) spectroscopy, $31-32$ infrared absorption spectroscopy, $33-34$ photoluminescence,34-36 and Raman spectroscopy.34 While Hi in the bond-centered site (*i.e.* HBC) has been identified as the most stable configuration, the vast number of configurations related to (V_{Zn} -*n*H) defect complexes is a complex issue that still needs to be clarified. In particular, the expected number of involved Hi atoms in that defect complex has not been completely identified yet. Several reports have contradictorily shown from DFT calculations that $(V_{Zn-}2H)$ or $(V_{Zn-}3H)$ could be the most stable defect complexes.^{21, 29-30, 37-39}

More importantly, the electronic structure properties of unintentionally doped ZnO NWs grown by CBD have mostly been related to the formation of single vacancies including V_0 and V_{Zn} .⁴⁰⁻⁴¹ However, no direct correlation has thoroughly been achieved with hydrogen although the growth medium is full of hydrogen atoms in the form of water molecules and hydroxide ions. Numerous investigations have shown the effects of post-deposition treatments under hydrogen atmosphere or plasma on the properties of ZnO NWs grown by CBD to passivate *VO* and V_{Zn} and likely form $(V_{Zn} - nH)$ defect complexes as well as to increase their electrical conductivity.42-47 These investigations have suggested that a hydrogen incorporation may occur during their growth by CBD. Huang *et al*. revealed the presence of hydrogen in ZnO NWs grown by CBD using nuclear magnetic resonance.48 Urgessa *et al.* identified the predominance

of the I_4 line assigned to H_0 in the near-band edge (NBE) emission of the photoluminescence spectra of ZnO NWs grown by CBD and investigated their stability as a function of annealing temperature.49 Barbagiovanni *et al.* measured the presence of hydrogen in ZnO NWs grown by CBD by using elastic recoil detection analysis, but they excluded the significant role of hydrogen-related defects in their optical properties.50 Later on, Cossuet *et al.* revealed that the high electrical conductivity of polarity-controlled vertical ZnO nanorods grown by CBD using the selective area growth approach is due to the massive incorporation of hydrogen.¹⁴ This was additionally found to be dependent upon their O- or Zn-polarity: O- and Zn-polar ZnO nanorods were shown to exhibit the predominant I_4 and I_5 lines assigned to H_0 and $(V_{Zn}-nH)$ with an unknown *n*, respectively. However, no experimental data were shown in the most widely used spontaneous growth approach using a polycrystalline ZnO seed layer that typically results in the formation of ZnO NWs with a much smaller diameter. No theoretical data were reported either to identify the most stable configurations of hydrogen-related defects.

In the present article, we combine four-point probe and low-temperature cathodoluminescence measurements collected on single ZnO NWs grown by CBD, as well as Raman spectroscopy with DFT calculations to unambiguously show the major role of hydrogen in their electronic structure properties. The most stable configurations of hydrogen-related defects in ZnO NWs are identified with care by coupling theoretical and experimental data, opening the way for tuning their electronic structure properties and thus their optical/electrical properties as an important requirement for improving the performances of the related nanoscale devices. The origin of the visible and ultra-violet emission bands in the luminescence spectra is also revisited and mainly related to V_{Zn} and $(V_{\text{Zn}}-nH)$ defect complexes.

2. METHODS

2.1. Synthesis of ZnO nanowires. The synthesis of ZnO NWs was performed following a double-step process. First, the polycrystalline ZnO seed layers were deposited by dip coating on Si (100) substrates pre-cleaned with acetone and isopropyl alcohol in an ultrasonic bath. A solution containing 375 mM of zinc acetate dihydrate (Zn(CH3COO)2.2H2O, Sigma-Aldrich) and 375 mM of monoethanolamine (MEA, Sigma-Aldrich) in pure ethanol was initially stirred for several hours at 60 °C on a hot plate and then at room temperature. The substrates were subsequently dipped in the solution under a controlled atmosphere $(< 15 %$ hygrometry) and annealed for 10 min at 300 °C on a hot plate and for 1 h at 500 °C in an oven under air. Second, ZnO NWs were grown by CBD in a sealed reactor containing an aqueous solution of zinc nitrate hexahydrate (Zn(NO₃)₂.6H₂O, Sigma-Aldrich) and hexamethylenetetramine (HMTA, Sigma-Aldrich) mixed in an equimolar ratio of 30 mM and placed for 5 h in an oven kept at 85 °C corresponding to a pH value around 5.5.

2.2. Characterization techniques. The morphological properties of ZnO NWs were investigated with a FEI Quanta 250 field-effect scanning electron microscopy (FESEM) instrument. 5 K cathodoluminescence measurements of ZnO NWs were performed with a FEI Inspect F50 FESEM equipped with a liquid helium-cooled stage. The cathodoluminescence signal was collected through a parabolic mirror and analyzed with a 550 mm focal length monochromator equipped with 600 grooves/mm diffraction grating. Cathodoluminescence spectra were recorded with a thermoelectric cooled silicon CCD detector using the low acceleration voltage of 5 kV and small spot size (i.e., less than 10 nm). Raman spectroscopy was performed by using a Horiba/Jobin Yvon Labram spectrometer equipped with a liquid nitrogen-cooled CCD detector. The 514.5 nm line of an $Ar⁺$ laser with a power on the sample surface close to 0.64 mW was focused to a spot size close to 1 μ m² using a 50 times long working distance objective. The integration time was dependent upon the spectral region and ranged from 2 min for low wavenumbers to 1 h for the hydrogen-related phonon modes. The spectra were calibrated using a silicon reference sample at room temperature by fixing the theoretical position of the silicon Raman line to 520.7 cm^{-1} . The four-terminal single ZnO NW devices with ohmic contacts using Ti / Au (50 nm / 50 nm) were fabricated using a Leo 1530 SEM equipped with a RAITH Elphy electron beam lithography (EBL) system and a PLASSYS e-beam deposition chamber. The electrical access was provided by four-probe nanomanipulators located in a FEI Inspect F50 FESEM instrument using a Keithley 2636B sourcemeter.

2.3. Density-functional theory method. The investigation of the wurtzite structure of ZnO and of the corresponding point defects was performed using the VASP code with projector augmented-wave (PAW) potentials⁵¹⁻⁵² under the Perdew-Burke-Ernzerh derivation of the generalized gradient approximation $(GGA-PBE)^{53-54}$ of the DFT. The reciprocal-space resolution for *k*-point mesh generation was set by a Monkhorst-Pack mesh of 8x8x6 for the 1x1x1 unit cell, while the *k*-point mesh was *Γ*-centred and the cut-off energy was set to 600 eV. In the present investigation, a 4x4x3 supercell consisting of 192 atoms was considered, while convergence with respect to *k*-point sampling, slab and vacuum thickness was explicitly checked. Extensive tests concluded that smaller cells or multiple defects in the 4x4x3 supercell are insufficient for the structural relaxation and the accurate calculations of the optoelectronic properties of point defects in ZnO. Reliable optical properties require an accurate determination of the electronic structure of the band gap. Hence, the DFT+*U* method was used in order to accurately calculate the electronic structure properties and consequently the optical properties. Initially, *U* was incorporated only for the *d*-states of Zn and the *Ud,Zn* was set to 7.5 following Ref. 55, a parameter value that produces good lattice constants, and significantly improves the bandgap energy of ZnO from 0.70 eV (GGA-PBE) to 1.85 eV. Nevertheless, it has been evidenced in Ref. 56 that the correct band gap energy of 3.4 eV for ZnO can be obtained, if in addition to the *U* values for the *d*-states, *U* values are considered also for the *s*- or *p*-states. The corresponding *U* values were obtained from R.M. Sheetz *et al.*:⁵⁷ *U*_{d,Zn}=10.5 eV, *U*_{s,Zn}=0 eV, and $U_{p,0}=7.0$ eV. In principles, the values of oxygen chemical potential μ_0 lie in the range of -

4.22 (*i.e.* formation enthalpy of ZnO) to 0 eV. In the present calculations, μ_0 was set to -2.11 eV, corresponding to intermediate growth conditions (*i.e.* in the middle of O- and Zn-rich conditions). The formation energies were calculated using the well-established formalisms described in Ref. 16. The formation energy of a complex point defect (*D*) in a charge state (*q*) depends on the growth conditions and on the influence of the environment expressed by the chemical potentials μ through the equation:

$$
E^{f}(D^{q}) = E_{tot}(D^{q}) - E_{tot}(bulk) - \sum_{i} n_{i}\mu_{i} + q(E_{F} + E_{VBM}) + E_{corr}
$$

where $E_{tot}(D^q)$ is the total energy of a supercell containing a single defect D^q in charge state q , and $E_{tot}(bulk)$ is the total energy of a perfect equivalent supercell. n_i represents the number of either host or impurity atoms of type *i*, which was added $(+n_i)$ to or removed $(-n_i)$ from the supercell in order to form the complex point defect D . μ_i represents the chemical potentials of the corresponding species of type *i*. The Fermi level E_F was considered with respect to the energy of the valence band maximum (VBM) E_{VRM} of the perfect crystal, which was further corrected by aligning the average electrostatic potential in the perfect crystal and a bulk-like area of the defected supercell. The correction term E_{corr} was considered with respect to the finite k-point sampling and/or elastic, electrostatic interactions between the defected supercells as described in detail in Refs. 58-60.

3. RESULTS

3.1. Morphological properties of ZnO nanowires. The growth of unintentionally doped ZnO NWs by CBD was achieved under standard conditions on a *c*-axis oriented polycrystalline ZnO seed layer deposited by dip coating on silicon.⁶¹ A sealed reactor containing an equimolar mix of zinc nitrate hexahydrate and hexamethylenetetramine (HMTA) in aqueous solution was placed in a regular oven for 5 h at 85 °C, corresponding to a pH value around $5.5.^{62}$ The morphology of ZnO NWs is presented in **Figure 1**, showing the formation of vertically aligned

nano-objects that preferentially nucleate on the ZnO nanoparticles with the semi-polar and polar orientations in the seed layer.⁶³ The typical mean diameter and length of ZnO NWs are of 100 \pm 27 nm and 1560 \pm 71 nm, respectively.

Figure 1. Cross-sectional- and top-view FESEM images of ZnO NWs grown by CBD under standard conditions using the spontaneous growth approach. The scale bar corresponds to 500 nm and 250 nm for the cross-sectional view and top-view images, respectively.

3.2. Electrical properties of ZnO nanowires. To investigate their electrical properties, several ZnO NWs were dispersed on dedicated silicon wafers covered with a 100 nm-thick SiO₂ layer grown by thermal oxidation for their processing. The ohmic contacts using Ti/Au (50 nm / 50 nm) metallization were fabricated by EBL. The electrical measurements were subsequently recorded in patterned metal contact configuration. The four-point manipulator probes in a FEI Inspect F50 FESEM instrument were placed on the EBL patterned Ti/Au local ohmic contacts. The current varying in the range of a few microamperes was injected from the outer contacts while the voltage was measured across the two inner contacts separated by a length *l*, as shown in the inset of **Figure 2a**. The resistance *R* of each ZnO NW between the two inner contacts was deduced from the slope of the I-V linear curve, as revealed in **Figure 2a**. A special emphasis was made to fix the range of electron beam dose used to desorb the oxygen species adsorbed on the NW surfaces, which are responsible for the carrier depletion leading to the huge apparent resistance of the NW.⁶⁴ The evolution of the resistance as a function of the electron beam dose is presented in **Figure S1**. A value of 1 x $10^5 \mu$ C/cm² was used for the electron beam dose before the resistance measurement of each NW, which was further taken

once the current vs time was stable to avoid any persistent conductivity.65-66 A statistical analysis of the four-probe resistance *R* over the length *l* as a function of the NW radius *r* was achieved over a population of six ZnO NWs, as presented in **Figure 2b**, along with experimental data reported on unintentionally doped ZnO NWs grown by carbothermal reduction,¹² metal-organic chemical vapour deposition (MOCVD),⁶⁵ hydrothermal method,¹² and CBD.14

Figure 2. (a) Current-voltage (I-V) measurement using a four-point probe configuration on a single ZnO NW grown by CBD under standard conditions using the spontaneous growth approach. The inset is a top-view FESEM image of the single NW device in patterned metal contact configuration. The current is injected from the two outer contacts and the voltage drop is measured from the two inner contacts. (b) *R*/*l* versus *r* along with experimental data reported

on unintentionally doped ZnO NWs grown by carbothermal reduction,¹² MOCVD,⁶⁵ hydrothermal method,¹² and CBD.¹⁴

The ZnO NWs exhibit *R*/*l* values varying in the range of 4.6 x 10³ to 4.0 x 10⁴ Ω/μ m with their radius *r* ranging from 43.5 to 62.5 nm. The electrical resistivity ρ is written as *RS*/*l*, in which *S* represents the conduction section. In the range of radius considered, a bulk-like conduction dominated by the core of the NW is expected and hence *S* is given by $S_{vol} = \pi r^2$ in a flat-band regime. The present experimental data together with the one reported in Ref. 14 on unintentionally doped Zn-polar ZnO nanorods grown by CBD under identical conditions using the selective area growth approach are delimited in **Figure 2b** by $1/r^2$ dependences corresponding to a bulk-like conduction. Following this procedure, the mean electrical resistivity of ZnO NWs is found to be in the range of $4.1 - 28.4$ m Ω cm, corresponding to a high electrical conductivity of $35.2 - 243.1$ S/cm. It is further deduced that the single ZnO NWs measured electrically in the present investigation very likely exhibit the Zn-polarity.14 By assuming that the electron mobility in ZnO NWs varies from 50 to 80 cm^2/Vs as typically reported from field-effect transistor (FET) measurements,⁶⁷⁻⁶⁸ the carrier density lies in the range of 2.7 x 10^{18} to 3.1 x 10^{19} cm⁻³. Additional FET measurements of these NWs revealed no channel conduction modulation versus backgate bias voltage up to -50 V. For higher backgate bias voltage, the $SiO₂$ layer breakdown occurred. By considering that the NW radius is about 50 nm and that the capacitance is overestimated by a factor of 2.5 ,⁶⁹ this shows that the carrier density is above 2.6 x 10^{18} cm⁻³. This confirms that the lowest value of the carrier density in the deduced range is very close to the effective critical concentration n_c of 4.2 x 10¹⁸ cm⁻³ corresponding to the Mott transition separating the non-metal/insulator from metal regimes in terms of electrical conduction.70 Most of these NWs thus exhibit a metallic electrical conduction. This high electron density in unintentionally doped ZnO NWs grown by CBD cannot be explained by the only role of single vacancies including *V*_O nor by the incorporation

of residual extrinsic impurities including aluminum, gallium or indium because i) no metal additives were used here and because ii) the range of pH below 7 in the present standard conditions is associated with unfavorable electrostatic repulsions between the possible residual metal cations and positively charged surfaces of ZnO NWs.71-72 Instead, it should be noted that the crystallization process of ZnO NWs by CBD typically occurs through the dehydration process of $[Zn(H_2O)_6]^{2+}$ ions, as shown by x-ray absorption near-edge structure measurements in Ref. 73 and by the modeling of the NW elongation process in Refs. 74-75. This crystallization process is highly favorable for the massive incorporation of hydrogen in the center of ZnO NWs. Additionally, the chemical precursors contain carbon and nitrogen, which may play a role as well.

3.3. Structure of crystal defects using density-functional theory. In order to investigate in more details the role of hydrogen in ZnO, we performed DFT calculations using the VASP code with PAW potentials⁵¹⁻⁵² under the GGA-PBE.⁵³⁻⁵⁴ A 4x4x3 supercell consisting of 192 atoms was considered for thoroughly investigating the wurtzite structure of ZnO and the corresponding point defects. The DFT+*U* method was used in order to accurately calculate the electronic structure properties and consequently the optical properties with *U* values taken for the *s*- and *d*-states of Zn atoms as well as for the *p*-states of O atoms from R.M. Sheetz *et al*.:⁵⁷ $U_{d,Zn}$ =10.5 eV, $U_{s,Zn}$ =0 eV, and $U_{p,O}$ =7.0 eV. In the present calculations, μ o was set to -2.11 eV, corresponding to intermediate growth conditions (*i.e.* in the middle of O- and Zn-rich conditions). The formation energies were calculated using the well-established formalisms described in Ref. 16. The formation energies of V_{Zn} and $(V_{\text{Zn}}-nH)$ defect complexes with $n=1$ -4 as a function of the Fermi level are presented in **Figure 3a**. The transition levels of the different thermodynamic charge states of V_{Zn} and $(V_{\text{Zn}}-nH)$ defect complexes are summarized in **Figure 3b**.

Figure 3. (a) Formation energies of hydrogen-related defects in ZnO as a function of the Fermi level, obtained from DFT calculations. For each charge state, only the most stable configuration with the lowest energy is presented. The zero of Fermi energy was chosen at the VBM. Chemical potential values of μ ^O = -2.11 eV and μ _H = -0.475 eV were used. (b) Transition levels of each of *V*Zn, (*V*Zn-H), (*V*Zn-2H) defect as a function of the vertically aligned Fermi level.

As expected from previous investigations reporting DFT calculations,¹⁶⁻¹⁷ V_{Zn} is a deep acceptor with a -2 charge state and low formation energy when the Fermi level is close to the CBM. In contrast, H_{BC} with the +1 charge state is a shallow donor with a very low formation energy regardless of the Fermi level in the bandgap, which is in agreement with Refs. 27-28. The situation of $(V_{Zn} - nH)$ defect complexes strongly depends on the number *n* of involved H_i atoms. The (*V*Zn-H) complex is a deep acceptor with a -1 charge state and fairly low formation energy when the Fermi level is close to the CBM. It is thus unlikely to be ionized at room temperature. In contrast, the (V_{Zn-2H}) complex is neutral and exhibits a low formation energy over a broad range of Fermi level. Both defect complexes are liable to form in ZnO, but their electrical activity is low at room temperature. In contrast, it is shown that the $(V_{Zn-}3H)$ complex is a shallow donor with $a + 1$ charge state that exhibits a very low formation energy regardless of the Fermi level in the bandgap, suggesting a massive formation in ZnO along with a large electrical activity. In contrast, the (V_{Zn-4H}) complex with a neutral charge state exhibits a fairly high formation energy regardless of the Fermi level in the bandgap and thus is not expected to play a significant role here. All the atomic configurations of the (V_{Zn} -*n*H) defect complexes in the tetrahedral environment of the relaxed wurtzite structure were calculated and the most stable ones are represented in **Figure 4**. It should be noticed that in order to investigate the hydrogen incorporation at the position of a V_{Zn} , two inequivalent positions of H atoms should be considered. The axial position where an H atom saturates the axial oxygen atom and three equivalent basal positions where an H atom is bonded to the basal oxygen atom can be defined. The calculations concluded that for an odd number of H atoms (*i.e.* (*V*Zn-H) and (*V*Zn-3H)), one H atom is systematically bonded to the axial position. Only by the use of a single electron addition (*i.e.* $(V_{Zn}-H)^{-1}$) or for the cases of even number of H atoms (*i.e.* $(V_{Zn}-2H)$), the basal positions are preferential. These basal positions of the H atoms in V_{Zn} with the presence of an axial O dangling bond have already been identified experimentally.⁷⁶⁻⁷⁷ The corresponding electronic band structures are given in **Figure S2**. Eventually, the present DFT calculations show that H_{BC} and $(V_{Zn-}3H)$ defect complex are both shallow donors, which should be considered as the major source of n-type conductivity in ZnO grown in a hydrogen-rich medium along with H_o.

Figure 4. Structural models for the most stable atomic configurations of each of $(V_{Zn}-H)$, $(V_{Zn}-H)$ 2H), and (V_{Zn} -3H) defect complex. Large grey balls denote Zn atoms, small red balls denote oxygen atoms and small white balls denote hydrogen atoms. The Zn atom in front of the V_{Zn} was removed for the sake of clarity and only its bonds with the neighboring oxygen atoms are presented.

3.4. Cathodoluminescence spectra and their assignment to crystal defects using density-functional theory. In order to correlate these theoretical data with experimental data, cathodoluminescence measurements collected on the ZnO NWs grown by CBD under standard conditions using the spontaneous growth approach were achieved at low temperature. A typical spatially-resolved 5K cathodoluminescence spectrum is presented in **Figure 5a**, along with a zoom-in in the NBE in **Figure 5b**.

Figure 5. (a) Typical 5K cathodoluminescence spectrum of unintentionally doped ZnO NWs grown by CBD under standard conditions using the spontaneous growth approach. The insets represent the emission energy of transitions as inferred from DFT calculations in this work and in Refs. 21, 39. (b) Corresponding NBE emission region. The insets represent the emission energy of transitions as inferred from DFT calculations in this work and from experimental data in Refs. 34, 36.

The NBE emission is dominated by radiative transitions involving neutral donor-bound Aexcitons pointed at 3.36 eV. From the *I* nomenclature used to label the excitonic lines,³⁵ the shape and position of the NBE emission may be attributed to the occurrence of the *I*4 and *I*⁵ lines at 3.3628 and 3.3614 eV related to H_O and (V_{Zn} -nH) defect complexes with an unknown *n*, respectively.^{34, 36} The line assigned to H_{BC} around 3.360 eV is also involved.³⁴ The visible

emission band is marked by the highly intense red-orange band centered at 1.86 eV and by the less intense yellow/green band centered at 2.25 eV along with a green/blue band centered at 2.65 eV. Although *V*_O has been related to the yellow/green emission band⁷⁸ of Z_nO NWs grown by CBD⁷⁹⁻⁸² and of ZnO nanocrystals, $83-84$ it should be noted here that its role has recently been questioned by DFT calculations.²¹ The related emission energies corresponding to the $(+1/0)$ and $(+2/+1)$ transitions levels were shown to be smaller than 1 eV and thus do not lie in the range of energy probed in the cathodoluminescence spectra. In the present case, it is worth noticing that $Zn(II)$ species are the limiting reactants in the CBD of $ZnO NWs$.⁷⁵ As such, the growth by CBD typically occurs under intermediate or oxygen-rich conditions, which are less favorable for the formation of a high density of V_0 as reported by DFT calculations.¹⁶⁻¹⁷ To understand the present experimental data, the hydrogen-related defect luminescence positions were calculated within the Franck-Condon approximation in the framework of the effective one-dimensional configuration coordinate *Q* as described in Refs. 21, 39. The zero phonon line energy (E_{ZPL}) and change in configuration coordinate ΔQ were computed using the DFT+ U method. The resulting emission energy (*E*emission) and absorption energy (*E*absorption) as reported in **Table 1** were deduced from the following relations: $E_{\text{emission}} = E_{\text{ZPL}} - \Delta E_{\text{g}}$ and $E_{\text{absorption}} =$ $E_{\text{ZPL}} + \Delta E_e$ where ΔE_g and ΔE_e are the relaxation energies of the ground and excited states referred as Franck-Condon shifts.

	Transition level	$E_{transition}$ (eV)	$E_{\rm emission}$ (eV)	E_{ZPL} (eV)	$E_{\text{absorption}}$ (eV)
$V_{\rm Zn}$	ϵ (+2/+1)	0.83	2.53	2.57	2.75
	ϵ (+1/0)	0.85	2.48	2.55	2.65
	$\epsilon(0/-1)$	0.96	2.19	2.44	2.71
	$\epsilon(-1/-2)$	1.25	1.60	2.15	3.08
V_{7n} -H	ϵ (+2/+1)	0.87	2.49	2.53	2.74
	ϵ (+1/0)	0.89	2.40	2.51	2.66
	$\epsilon(0/-1)$	1.09	1.82	2.31	2.93
V_{7n} -2H	ϵ (+2/+1)	0.89	2.46	2.51	2.96
	ϵ (+1/0)	0.92	2.29	2.48	2.86
V_{7n} -3H	$\epsilon(+1/0)$		3.37	3.4	3.64

Table 1. Effective parameters for the calculated luminescence transitions, including *E*transition, *E*emission, *E*ZPL, and *E*absorption. The grey colored font enlightens the expected thermodynamic charge state of each defect when the Fermi level is close to the CBM.

The emission energy of 3.37 eV corresponding to the $(+1/0)$ transition level of the $(V_{Zn-}3H)$ defect complex lies in the NBE emission band. This statement supports the involvement of the I_5 line in that band and its assignment to the $(V_{Zn-}3H)$ defect complex as suggested in Ref. 36. Interestingly, the emission energy of 1.82 eV corresponding to the $(0/-1)$ transition level of the (*V*Zn-H) defect complex very well matches the energetic position of the red/orange emission band. This indicates the predominant involvement of that defect complex in the red/orange emission band. This assignment is in good agreement with a previous investigation suggesting the involvement of V_{Zn} -based defect complexes in the red emission band.⁸⁵ The emission energy of 1.60 eV corresponding to the $(-1/-2)$ transition level of the V_{Zn} may also be involved to some extent. The small shoulder in the red/orange emission band around 1.60 eV is thus assigned to *V*Zn. This assignment is in good agreement with a previous investigation suggesting that the red emission band in ZnO NWs grown by CBD is associated with the V_{Zn} .⁴⁵ Additionally, the emission energy of 2.29 eV corresponding to the $(+1/0)$ transition level of the (V_{Zn-2H}) defect complex is also in very good agreement with the energetic position of the yellow/green emission

band. This statement supports the involvement of the $(V_{Zn-}2H)$ defect complex in that band. This assignment is in good agreement with previous investigations suggesting the involvement of V_{Zn} -based defect complexes in the green emission band of ZnO NWs.⁸⁶⁻⁸⁷ (V_{Zn} -H) and (V_{Zn} -2H) defect complexes are thus formed in the bulk of ZnO NWs and clearly assigned in the cathodoluminescence spectra. Other emission energies associated with different charge states of *V*Zn, (*V*Zn-H) and (*V*Zn-2H) may fit the energetic position of the yellow/green emission band, but i) the direct formation of these defects is unlikely when the Fermi level is close to the CBM and ii) their indirect formation through the capture of one or several holes from the corresponding stable defects with the expected charge state is unlikely as well in the bulk of ZnO NWs with a high electron density. The small discrepancies on the emission energy of these hydrogen-related defect complexes with previous DFT-based calculations^{21, 39} are owing to i) the 192-atom supercells that were used in the present investigation in contrast to the previously used 96-atom supercells as well as to ii) the aforementioned DFT+*U* approach that was used in the current study where in addition to the *U* values for the *d*-states, *U* values were also considered for the *s*- or *p*-states. Moreover, one should notice that zinc dangling bonds with a presumable high density on the surfaces of ZnO NWs grown by CBD may also contribute significantly to the yellow/green emission band with an expected emission energy around 2.41 eV.

The green/blue emission band centered at 2.65 eV is expected to originate from surface defects in ZnO NWs. Following the electron-hole pair generation from the electron beam with an energy of 5 keV, holes migrate from the bulk of ZnO NWs to their surfaces. The present phenomenon is due to the upward band bending related to a surface depletion region originating from the adsorbed oxygen ions.⁸⁸ This creates a region close to the surface where holes are highly concentrated. They affect the charge states of the V_{Zn} and $(V_{\text{Zn}}-nH)$ defect complexes, which can deviate from the most stable configurations. Accordingly, we expect from **Table 1**

that the green/blue emission band is mostly related to the $(+1/0)$ and $(+2/+1)$ transition levels associated with the V_{Zn} , $(V_{\text{Zn}}-H)$, and $(V_{\text{Zn}}-2H)$ defect complexes. In that sense, the green/blue emission band originates from the V_{Zn} and hydrogen-related defects on the surfaces of ZnO NWs, which are probed under the typical conditions used with an electron beam or an UV radiation. This assignment is in good agreement with previous investigations attributing the green emission band to surface defects^{85, 89} like V_{Zn} , ⁹⁰⁻⁹¹ which can exhibit a lower formation energy on the surfaces of ZnO NWs.⁹²

In brief, the visible and ultra-violet emission bands are found to be mostly assigned to V_{Zn} and (V_{Zn} -*n*H) defect complexes located in the bulk and on the surfaces of unintentionally doped ZnO NWs grown by CBD.

3.5. Raman scattering spectra and their assignment to crystal defects. To complement the cathodoluminescence measurements, Raman spectroscopy collected on the ZnO NWs grown by CBD under standard conditions using the spontaneous growth approach was performed at room temperature. A typical Raman spectrum is presented in **Figure 6a**. The typical optical phonon modes that are characteristic of the wurtzite structure of ZnO occur in the wavenumber range of 50-900 cm^{-1 o3} The Raman lines at 99, 378, 438, and 574 cm⁻¹ are assigned to the E_2^{low} , $A_1(TO)$, E_2^{high} , and $A_1(LO)$ modes, respectively. Second-order Raman lines at 203, 483, 666, and 812 cm⁻¹ correspond to $2TA/2E_2^{low}$, 2LA, TA+LO, and LA+TO modes, respectively. The Raman line at 333 cm⁻¹ is usually attributed to the $E_2^{\text{high}}-E_2^{\text{low}}$ mode, 93 but it may also originate from the 1s \rightarrow 2p donor state transition involving H_{BC}.³⁴ Similarly, the shoulder around 273 cm⁻¹ may also come from the 1s \rightarrow 2p donor state transition involving H_O.³⁴ No sign for the presence of additional modes occurs in that wavenumber range either, excluding again the possible incorporation of residual extrinsic impurities such as aluminium, gallium or indium.^{71-72, 94} In the high wavenumber range of 2750-3000 cm⁻¹, the sharp Raman lines correspond to antisymmetric and symmetric stretching bonds of CH_x groups.⁹⁵ The

presence of carbon certainly originates from the adsorption of residual HMTA molecules on the surfaces of ZnO NWs. It is well-known that HMTA as one of the two chemical precursors during the CBD process adsorbs on the *m*-plane sidewalls of $ZnO NNs.$ ^{62, 96-97} Its use is achieved to inhibit the radial growth of ZnO NWs and increase their aspect ratio. No sign for the incorporation of carbon in the bulk of ZnO NWs occurs. In particular, the typical *Z*-lines attributed to carbon-related defects in photoluminescence spectra have been shown in ZnO NWs grown by metal-organic vapor phase epitaxy,⁹⁸ but their presence has not been revealed in ZnO NWs grown by CBD.¹⁴ This supports the presence of carbon mostly on the surfaces of ZnO NWs. Correlatively, the intense Raman line at 3078 cm^{-1} can be assigned to nitrogenrelated bonds.⁹⁵ Again, the presence of nitrogen through the formation of N-H groups likely comes, to a large extent, from the adsorption of residual HMTA molecules on the surfaces of ZnO NWs.^{62, 96-97} No sign for the presence of additional modes related to substitutional nitrogen on the oxygen lattice site occurs.⁹⁹ The formation of highly stable N-H like defects in the bulk of ZnO NWs cannot be excluded, but they typically act as neutral defect complexes.¹⁰⁰⁻¹⁰² As a result, they cannot account for the high electron density of these ZnO NWs despite their possible involvement. More importantly, the signature of hydrogen on the surface and in the bulk of ZnO NWs largely occurs in the wavenumber range of 3200-3750 cm⁻¹ in the Raman spectrum. The dominant Raman line centered at 3575 cm^{-1} and with a FWHM of 70.5 cm⁻¹ is assigned to H_{BC} , as previously reported in Refs. 33, 103. The shoulder around 3500 cm⁻¹ is due to the O-H bonds on the surface of ZnO NWs, as typically assigned in Refs. 33, 104-105. More interestingly, the other intense Raman band centered at lower wavenumbers is basically composed of three distinct components as shown in **Figure 6b**. They are generally assigned to the (*V*Zn-*n*H) defect complexes. The (*V*Zn-H) defect complex results in Raman and infrared absorption lines lying in the range of $3306 - 3418$ cm⁻¹.^{21, 33} In contrast, the (V_{Zn} -2H) defect complex leads to infrared absorption lines pointing at 3312 and 3349 cm⁻¹,³³ whereas the $(V_{Zn}$ -

3H) defect complex gives rise to infrared absorption lines pointing at 3303 and 3321 cm⁻¹,³⁸ respectively. The presence of these hydrogen-related defects in the Raman spectrum is in very good agreement with the cathodoluminescence spectrum in **Figure 5**. This confirms their formation with a significant amount in ZnO NWs grown by CBD under standard conditions using the spontaneous growth approach.

Figure 6. (a) Typical Raman spectrum of unintentionally doped ZnO NWs grown by CBD under standard conditions using the spontaneous growth approach. (b) Corresponding high wavenumber region. The insets represent the calculated and experimental vibrational frequencies from Raman and infrared absorption spectroscopy as inferred from Refs. 21, 33, 38, 104-105.

4. DISCUSSION

ZnO NWs can be formed by a large number of physical and chemical deposition techniques in vapor phase or in solution by using the spontaneous growth approach (*i.e.* without any catalyst) owing to the highly anisotropic degree of the wurtzite structure. Their high electrical conductivity corresponding to a high electron density has been revealed regardless of the deposition techniques used^{12, 65} and in the present investigation as well. However, the origin of that high electron density should be distinguished and strongly depends on the deposition techniques used. While the high electron density in ZnO NWs grown by vapor phase deposition techniques has commonly been attributed to the significant incorporation of residual extrinsic impurities that inherently occur in the dedicated chamber,⁶⁵ it has been revealed here that the situation of ZnO NWs grown by CBD strongly differs. The metallic electrical conduction of unintentionally doped ZnO NWs and the correlated high electron density above 2.7 x 10^{18} cm⁻ 3 is instead due to the large incorporation of hydrogen in their center. Both cathodoluminescence and Raman spectroscopy measurements have clearly revealed the presence of H_{BC} and (*V*_{Zn} nH) defect complexes with $n = 1-3$ in the center of ZnO NWs, which is in excellent agreement with DFT calculations showing their low formation energy when the Fermi level is close to the CBM. While H_{BC} is a shallow donor that accounts, to a significant extent, for the source of ntype conductivity of ZnO NWs grown by CBD, the situation of the (V_{Zn} -nH) defect complexes strongly depends on the number *n* of involved H_i atoms. The formation of all the $(V_{Zn}-H)$, $(V_{Zn}-H)$ 2H), and (V_{Zn} -3H) defect complexes has been shown in the cathodoluminescence and Raman spectra. However, their electrical activity is highly distinct. The $(V_{Zn}-H)$ and $(V_{Zn}-2H)$ defect complexes acting as a deep acceptor and a neutral complex, respectively, have a limited impact on the electrical properties of ZnO NWs grown by CBD. Nevertheless, they are largely formed in the center of ZnO NWs owing to their low formation energy. Also they have a high impact on the optical properties of ZnO NWs, specifically through the respective i) red-orange and yellow/green emission bands when located in the bulk and ii) green/blue emission band when

located on the surfaces. In contrast, the $(V_{Zn}-3H)$ defect complex acting as a shallow donor with a very low formation energy regardless of the Fermi level in the bandgap should be considered as one of the major sources of n-type conductivity in ZnO NWs grown by CBD. Additionally, the role of H_O as a further shallow donor is also expected to play a significant role here. By considering that the hydrogen-related shallow donors are partially ionized, we further expect that the hydrogen concentration in ZnO NWs is huge and above $1-5 \times 10^{19}$ cm⁻³. The present findings promote hydrogen engineering as a capital issue in the field. They reveal that the hydrogen engineering in ZnO NWs grown by CBD is crucial for tuning their optical and electrical properties as an important issue for improving the performance of nanoscale devices integrating this type of objects. They further open the way for innovative strategies aiming at increasing or decreasing the density of hydrogen-related defects in ZnO NWs depending on the devices targeted, including post-deposition thermal heat treatments under different atmospheres and plasma for instance.

5. CONCLUSION

In summary, we have shown by four-point probe resistivity measurements that unintentionally doped ZnO NWs spontaneously grown by CBD under standard conditions exhibit a high electrical conductivity with electron densities lying in the range of 2.7 x 10¹⁸ to 3.1×10^{19} cm⁻³. Most of them have a metallic electrical conduction. This has been attributed from cathodoluminescence and Raman spectroscopy supported by DFT calculations to the formation of H_{BC} and $(V_{Zn}$ -3H) defect complexes acting as two shallow donors with a very low formation energy. Additionally, the assignment of the visible and ultra-violet emission bands in the cathodoluminescence spectra has been revisited with the help of DFT calculations, revealing the significant roles of V_{Zn} and $(V_{\text{Zn}}-nH)$ defect complexes located in the bulk and on the surfaces of ZnO NWs. The NBE emission band has been assigned to the $(V_{Zn-}3H)$ defect complex. In contrast, the red/orange and yellow/green emission bands lying at 1.86 and 2.25

eV have been attributed to the V_{Zn} and (V_{Zn} -H) defect complex as well as to the (V_{Zn} -2H) defect complex in the bulk of ZnO NWs, respectively. Importantly, the green/blue emission band at 2.65 eV has been assigned to the *V*Zn, (*V*Zn-H), and (*V*Zn-2H) defects located on the surfaces of ZnO NWs. These findings unambiguously identify the predominant native and extrinsic defects in unintentionally doped ZnO NWs grown by CBD to hydrogen-related defects, governing in turn their electronic structure properties. They further open many perspectives for optimizing the related optical and electrical properties of ZnO NWs as a critical requirement for a large number of nanoscale engineering devices.

ASSOCIATED CONTENT

Typical evolution of *R*/*l* as a function of the electron beam dose (**Figure S1**). Electronic band structures of the pristine ZnO and defected supercells (**Figure S2**).

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